IN THE CLAIMS

Please amend the claims as follows:

Claim 1 (Currently Amended): A method for evaluating the quality of abrasive grains for polishing glass, which comprises

adding abrasive grains to be measured, to an aqueous medium having comprising silica dissolved therein, to have the silica adsorbed

absorbing the silica on the abrasive grains under such a condition that the silica undergoes substantially no polymerization in the aqueous medium, followed by

solid-liquid separation to separate

separating the abrasive grains from the mother liquor, and

measuring the concentration of silica remaining in the <u>a</u> mother liquor to measure the <u>a silica</u> adsorption rate (η) of silica on the abrasive grains.

Claim 2 (Currently Amended): A method for polishing glass, wherein which comprises:

selecting or identifying abrasive grains grains, of which the having a silica adsorption rate (η) as measured by the method as defined in Claim 1 has having at most a certain value (η_0) , are selected or identified, and used for

polishing glass with the selected or identified abrasive grains.

Claim 3 (Currently Amended): The method for polishing glass according to Claim 2, wherein the value of η_0 is 50%.

Claim 4 (Currently Amended): An abrasive for polishing glass, which is an abrasive comprising, as the <u>a</u> main component, a rare earth oxide containing comprising cerium oxide,

wherein the <u>a</u> silica adsorption rate (η) on the abrasive grains, as measured by the method as defined in Claim 1, is at most 50%.

Claim 5 (Currently Amended): The abrasive for polishing glass according to Claim 4, which further contains comprises a fluorine compound.

Claim 6 (Currently Amended): The abrasive for polishing glass according to Claim 4, which further contains comprises an alkaline earth metal sulfate compound, and/or an alkaline earth metal phosphate compound, or both an alkaline earth metal sulfate compound.

and an alkaline earth metal phosphate compound.

Claim 7 (Currently Amended): The abrasive for polishing glass according to Claim 5, which further eentains comprises an alkaline earth metal sulfate compound, and/or an alkaline earth metal phosphate compound, or both an alkaline earth metal sulfate compound, and an alkaline earth metal phosphate compound.

Claim 8 (Original): The abrasive for polishing glass according to Claim 6, wherein the alkaline earth metal is at least one member selected from the group consisting of calcium, barium, magnesium and strontium.

Claim 9 (Currently Amended): The method for polishing glass according to Claim 2, wherein as the abrasive, one containing the abrasive grains having have a grain diameter of from 2 to 3 μ m, of which the measured value of the average grain strength by a micro compression testing machine is from 10 to 300 MPa. MPa, is used.

Claim 10 (Currently Amended): The abrasive for polishing glass according to Claim 4, which eentains comprises abrasive grains having a grain diameter of from 2 to 3 μ m, of which the measured value of the average grain strength by a micro compression testing machine is from 10 to 300 MPa.

Claim 11 (Currently Amended): The abrasive for polishing glass according to Claim 5, which eentains comprises abrasive grains having a grain diameter of from 2 to 3 μ m, of which the measured value of the average grain strength by a micro compression testing machine is from 10 to 300 MPa.

Claim 12 (Currently Amended): The abrasive for polishing glass according to Claim 6, which contains comprises abrasive grains having a grain diameter of from 2 to 3 μ m, of which the measured value of the average grain strength by a micro compression testing machine is from 10 to 300 MPa.

Claim 13 (New): The abrasive for polishing glass according to Claim 4, wherein the silica adsorption rate (η) on the abrasive grains is at most 40%.

Claim 14 (New): The abrasive for polishing glass according to Claim 4, wherein the silica adsorption rate (η) on the abrasive grains is at most 30%.

Claim 13 (New): The abrasive for polishing glass according to Claim 4, wherein the silica adsorption rate (η) on the abrasive grains is at most 20%.